	ass 205 is considered to be an	59	.Group IA metal-containing active material (e.g., Li, Na, K,
integral part of Class 204 (see the Class 204 schedule for the position of this Class in schedule hierarchy). This Class		60	<pre>etc.) .Nickel-containing active material</pre>
	all pertinent definitions and	61	Cadmium-containing
	ines of Class 204.	62	.Cadmium-containing active
			material
		63	.Lead-containing active material
		64	.Zinc-containing active material
43	ELECTROLYTIC PROCESS INVOLVING	65	.Silver-containing active
	ACTINIDE SERIES ELEMENTS OR		material
	COMPOUND (AT. NO. 89+) (PRODUCT, PROCESS,	66	.Iron- or tin-containing active material
	COMPOSITION, AND METHOD OF	67	ELECTROFORMING OR COMPOSITION
	PREPARING COMPOSITION)	07	THEREFOR
44	.Plutonium	68	.Recording device
45	.Thorium	69	.Printing plate or electrotype
46	.Uranium	70	.Mold, mask, or masterform
47	Utilizing fused bath	71	.Mirror or reflector
48	Involving electrolytic coating,	71 72	Ornamental article
40	etching, or polishing	• =	
49	Uranium containing compound	73	.Roll, ring, or hollow body
43	produced	74	.Powder, flakes, or colloidal particles
50	PRODUCT PRODUCED BY ELECTROLYSIS	75	Perforated or foraminous article
30	INVOLVING ELECTROLYTIC	75 76	
	MARKING, BATTERY ELECTRODE		.Sheet, web, wire, or filament
	ACTIVE MATERIAL FORMING,	77	Of indeterminate length
	ELECTROFORMING, OR	78	.Electrical product
	ELECTROLYTIC COATING	79	.Optical element
51	SUPERCONDUCTOR PREPARATION	80	ELECTROLYTIC COATING (PROCESS,
31	INVOLVING ELECTROLYTIC		COMPOSITION AND METHOD OF
	MARKING, ELECTROFORMING OR	0.4	PREPARING COMPOSITION)
	ELECTROLYTIC COATING, OR	81	.Involving measuring, analyzing,
	COMPOSITION THEREFOR		or testing
52	ELECTROLYTIC MARKING OR	82	Controlling coating process in
0.2	COMPOSITION THEREFOR		response to measured or
53	.Utilizing inorganic color-		detected parameter
33	forming material other than	83	Parameter is current, current
	carbon		density, or voltage
54	Carbon		
34	IItilizing organic color-forming	84	Parameter is thickness,
	.Utilizing organic color-forming	84	weight, or composition of
55	material		
55	<pre>materialHeterocyclic color-forming</pre>	84	weight, or composition of
	<pre>materialHeterocyclic color-forming material</pre>		weight, or composition of coating
55 56	<pre>materialHeterocyclic color-forming materialHydroxyl or carboxyl group-</pre>		<pre>weight, or composition of coating .Displacement or replacement</pre>
	<pre>materialHeterocyclic color-forming materialHydroxyl or carboxyl group- containing color-forming</pre>	85	<pre>weight, or composition of coating .Displacement or replacement coating</pre>
56	<pre>materialHeterocyclic color-forming materialHydroxyl or carboxyl group- containing color-forming material</pre>	85	<pre>weight, or composition of coating .Displacement or replacement coating .Employing internal battery</pre>
	<pre>materialHeterocyclic color-forming materialHydroxyl or carboxyl group- containing color-forming material UTILIZING ELECTROLYSIS TO FORM</pre>	85 86	weight, or composition of coating .Displacement or replacement coating .Employing internal battery action during coating
56	<pre>materialHeterocyclic color-forming materialHydroxyl or carboxyl group- containing color-forming material UTILIZING ELECTROLYSIS TO FORM BATTERY ELECTRODE ACTIVE</pre>	85 86	weight, or composition of coating .Displacement or replacement coating .Employing internal battery action during coating .Simultaneous deplating and
56	materialHeterocyclic color-forming materialHydroxyl or carboxyl group- containing color-forming material UTILIZING ELECTROLYSIS TO FORM BATTERY ELECTRODE ACTIVE MATERIAL OR COMPOSITION	85 86 87	weight, or composition of coating .Displacement or replacement coating .Employing internal battery action during coating .Simultaneous deplating and plating
56 57	materialHeterocyclic color-forming materialHydroxyl or carboxyl group- containing color-forming material UTILIZING ELECTROLYSIS TO FORM BATTERY ELECTRODE ACTIVE MATERIAL OR COMPOSITION THEREFOR	85 86 87	weight, or composition of coating .Displacement or replacement coating .Employing internal battery action during coating .Simultaneous deplating and plating .Utilizing subatmospheric or
56	materialHeterocyclic color-forming materialHydroxyl or carboxyl group- containing color-forming material UTILIZING ELECTROLYSIS TO FORM BATTERY ELECTRODE ACTIVE MATERIAL OR COMPOSITION THEREFOR .Organic active material other	85 86 87	weight, or composition of coating .Displacement or replacement coating .Employing internal battery action during coating .Simultaneous deplating and plating .Utilizing subatmospheric or superatmospheric pressure
56 57	materialHeterocyclic color-forming materialHydroxyl or carboxyl group- containing color-forming material UTILIZING ELECTROLYSIS TO FORM BATTERY ELECTRODE ACTIVE MATERIAL OR COMPOSITION THEREFOR	85 86 87 88	weight, or composition of coating .Displacement or replacement coating .Employing internal battery action during coating .Simultaneous deplating and plating .Utilizing subatmospheric or superatmospheric pressure during coating

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90	Ferromagnetic material deposited	112	.Coating is discontinuous single metal or alloy layer (e.g.,
91	.Utilizing electromagnetic wave		islands, porous layer, etc.)
91	energy during coating (e.g.,	113	Coating is microcracked
	visible light, etc.)	114	coating is microcracked .Uniting two separate solid
92	Energy produced by laser	114	materials
93	.Contacting coating as it forms	115	.Repairing
	with solid member or material	116	.Mirror or reflector produced
	other than electrode	117	.Utilizing brush or absorbent
94	.Utilizing mist prevention		applicator
95	.Coating has specified thickness	118	.Coating selected area
	variation	119	Depositing ferromagnetic
96	.Controlling current distribution		coating or coating
	within bath		ferromagnetic substrate
97	Shaped counterelectrode	120	Design or ornamental article
98	.Treating process fluid by means		produced
	other than agitation or	121	Predominantly nonmetal
	heating or cooling	121	electrolytic coating (e.g.,
99	Purifying electrolyte		anodic oxide, etc.)
100	Treating rinse solution (e.g.,	122	Specified product produced
100	rinse water, etc.)	123	Product is semiconductor or
101	Regenerating or maintaining	123	includes semiconductor
101	electrolyte (e.g., self-	124	Predominantly nonmetal
	regulating bath, etc.)	124	electrolytic coating (e.g.,
102	.Depositing predominantly single		anodic oxide, etc.)
102	metal or alloy coating on	125	Product is circuit board or
	single metal or alloy using	123	printed circuit
	specified waveform other than	126	Electroless coating from bath
	pure DC	120	containing metal ions and
103	Reversing current or voltage		reducing agent prior to
104	Nonreversing pulsed current or		electrolytic coating
	voltage	127	Product is printing member
105	.Depositing predominantly single	128	Simultaneous or sequential
103	metal or alloy coating on	120	coating of a plurality of
	nonmetal using specified		separate articles
	waveform other than pure DC or	129	Selectively coating moving
	60 Hz sine wave AC (e.g.,	127	substrate of indeterminate
	single metal or alloy coating		length (e.g., strip, wire,
	within or above pores of		fiber, etc.)
	anodic oxide layer, etc.)	130	Completely coating one side of
106	.Forming nonmetal coating using	130	strip
	specified waveform other than	131	Internal coating (e.g., coating
	pure DC or 60 Hz sine wave AC	131	inside of cylinder, etc.)
	(e.g., anodic oxide coating,	132	Moving counterelectrode
	etc.)	133	Directing electrolyte to
107	Reversing current or voltage	133	selected area (e.g., jet
108	Nonreversing pulsed current or		plating, etc.)
	voltage	134	Partially submerging substrate
109	.Coating contains embedded solid	134	in bath
	material (e.g., particles,	135	Utilizing specified mask
	etc.)	T 2 2	material
110	Abrasive article produced	136	
111	.Coating is dendritic or nodular	137	Utilizing means other than mask
		T 2 /	.Coating moving substrate

138	<pre>Indeterminate length (e.g., strip, wire, fiber, etc.)</pre>	163	Conductive material applied to substrate by painting,
139	Predominantly aluminum substrate		spraying, or immersion (e.g., electroless plating, etc.)
140	Tin-containing coating	164	Synthetic resin substrate
141	Zinc-containing coating	165	Conductive material applied to
142	Chromium-containing coating		substrate by vacuum or vapor
143	Rotary (e.g., barrel plating,		deposition
	etc.)	166	Conductive material applied to
144	Utilizing fluidized bed (e.g.,		substrate by painting,
	coating particles, flakes,		spraying, or immersion
	granules, etc.)	167	Conductive material applied
145	Simultaneous or sequential		to substrate by plating from
	coating of a plurality of		bath containing metal ions and
	separate articles		reducing agent (e.g.,
146	Reciprocating substrate		electroless plating, etc.)
147	.Applying current to substrate	168	Resin contains etchable
11/	without mechanical contact		filler
	(e.g., liquid contact, bipolar	169	Conductive material is
	electrode, etc.)		copper or nickel
148	.Agitating or moving electrolyte	170	.Forming multiple superposed
	during coating		electrolytic coatings
149	.Coating predominantly single	171	At least one anodic coating
	metal or alloy substrate of	172	Predominantly aluminum
	specified shape		substrate
150	Perforated, foraminous, or	173	Electrolytically depositing
	permeable substrate		material only within or above
151	Cylinder, roll, or hollow		pores of anodic coating (e.g.,
	article		electrolytic coloring, etc.)
152	Sheet, plate, or foil	174	Multiple anodic coatings
153	Predominantly aluminum	175	Multiple anodic coatings
	substrate	176	At least one alloy coating
154	Tin-containing coating	177	At least one predominantly zinc
155	Zinc-containing coating		metal coating
156	Chromium-containing coating	178	At least one chromium-
157	.Coating predominantly		containing coating
	semiconductor substrate (e.g.,	179	Multiple chromium-containing
	silicon, compound		coatings
	semiconductor, etc.)	180	At least one predominantly
158	.Coating a substrate		nickel metal coating
	predominantly comprised of	181	At least one predominantly
	nonconductive material to		nickel metal coating
	which conductive material or	182	At least one predominantly
	material which can be		copper metal coating
	converted into conductive	183	.Forming nonelectrolytic coating
	material has been added (e.g.,		before depositing
	nonconductive polymer		predominantly single metal or
	substrate containing carbon or		alloy electrolytic coating
	copper oxide particles, etc.)	184	Nonelectrolytic coating or
159	.Coating predominantly nonmetal		coatings all contain single
	substrate		metal or alloy
160	Fabric substrate	185	Nonelectrolytic coating from
161	Perforated, foraminous, or		zincate or stannate bath
1.55	permeable substrate	186	Nonelectrolytic coating by
162	Ceramic or glass substrate		vacuum or vapor deposition

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187	Nonelectrolytic coating by	204	Sealing agent includes
	plating from bath containing		organic constituent
	metal ions and reducing agent	205	.Treating substrate prior to
	(e.g., electroless plating,		coating
	etc.)	206	Contacting substrate with solid
188	.Forming nonelectrolytic coating		member or material (e.g.,
	before forming nonmetal		polishing, rolling, etc.)
	electrolytic coating	207	Heating substrate
189	Predominantly titanium,		-
109	<u> </u>	208	Blasting substrate with
	vanadium, zirconium, niobium,		particulate material
	hafnium, or tantalum	209	Heating substrate other than by
	nonelectrolytic coating		contact with liquid
190	Predominantly aluminum	210	Treating substrate with liquid
	nonelectrolytic coating		other than tap water (e.g.,
191	.Forming nonelectrolytic coating		for removing foreign material,
	after depositing predominantly		etching, activating, etc.)
	single metal or alloy	211	Liquid is nonaqueous (e.g.,
	electrolytic coating	211	hydrocarbon solvent, fused
192	Nonelectrolytic coating by		bath, etc.)
-7-	vacuum or vapor deposition of	010	
	a predominantly single metal	212	Predominantly titanium,
	or alloy coating		vanadium, zirconium, niobium,
193			hafnium, tantalum, molybdenum,
193	Nonelectrolytic coating by		or tungsten substrate
	immersion in bath of molten	213	Predominantly aluminum
	metal to form predominantly		substrate
	single metal or alloy coating	214	Graining or roughening
	(e.g., hot dipping, etc.)		chemically or electrolytically
194	Nonelectrolytic coating is	215	Predominantly copper, zinc, or
	predominantly nonmetal		tin substrate
195	Nonelectrolytic coating is	216	Predominantly cobalt or nickel
	ceramic, glass, or vitreous	210	
	enamel	0.1 🗆	substrate
196	Nonelectrolytic coating is	217	Predominantly iron or steel
100	predominantly organic material		substrate
	(e.g., paint, etc.)	218	Steel containing chromium or
197	Nonelectrolytic coating is		nickel (e.g., stainless steel,
197			etc.)
	phosphorus- or chromium-	219	Electrolytic treatment
	containing (e.g., phosphate,	220	.Treating electrolytic or
	chromate, etc.)		nonelectrolytic coating after
198	.Forming nonelectrolytic coating		it is formed
	after forming nonmetal	221	Selected area
	electrolytic coating	222	Contacting with solid member or
199	Electrolytic coating is oxygen-	222	
	containing (e.g., chromate,		material (e.g., buffing,
	silicate, oxide formed by	000	burnishing, polishing, etc.)
	anodizing, etc.)	223	Etching of coating
200	Predominantly titanium,	224	Heating
	vanadium zirconium, niobium,	225	Tin-containing coating
	hafnium, or tantalum substrate	226	Coating is fused (e.g.,
201	Predominantly aluminum		reflowing, flow brightening,
∠ () ⊥	-		etc.)
202	substrate	227	Single metal or alloy coating
202	Nonelectrolytic coloring		on single metal or alloy
	(including nonelectrolytic		substrate
	coloring and sealing)	228	Coating is at least partially
203	Sealing	220	diffused or forms alloy
			attrused of totills attroy

229	Predominantly nonmetal	260	Organic sulfoxy-containing
	electrolytic coating	261	.Depositing predominantly single
230	.Utilizing fused bath		metal coating
231	<pre>Reactive coating (e.g., by diffusion, etc.)</pre>	262	<pre>Group VIIB transition metal (i.e., Mn, Tc, or Re)</pre>
232	Depositing predominantly alloy	263	Silver
	coating	264	Platinum group metal
233	Depositing aluminum coating	265	Palladium
234	.Utilizing nonaqueous bath	266	Gold
235	Coating is predominantly organic material	267	Utilizing organic compound- containing bath
236	Depositing predominantly alloy	268	Inorganic cyanide-containing
	coating	269	Cobalt
237	Deposition aluminum coating	270	Iron
238	.Depositing predominantly alloy	271	Nickel
200	coating	272	Utilizing specified anode
239	Copper-containing alloy	272	
240	Including zinc (e.g., brass,		Utilizing sulfamate-containing bath
0.44	etc.)	274	Utilizing organic sulfoxy
241	Including tin (e.g., bronze,		compound-containing bath
	etc.)	275	And acetylenic compound-
242	Including noble metal (e.g.,		containing
	gold-copper-cadmium alloy,	276	And polyether-containing
	etc.)	277	And nitrogen-heterocyclic
243	Chromium is predominant		compound-containing
	constituent	278	Utilizing oxygen-heterocyclic
244	Zinc is predominant constituent		compound-containing bath
245	Including iron group metal	279	Utilizing nitrogen-
	(i.e., Fe, Co, or Ni)		heterocyclic compound-
246	Nickel		containing bath
247	Gold is predominant constituent	280	Utilizing organic carbonyl
248	Utilizing sulfite-containing		compound-containing bath
	bath	281	Cadmium
249	Utilizing phosphonic or	282	Utilizing inorganic cyanide-
	phosphinic acid or derivative-	202	containing bath
	containing bath	283	Chromium
250	Including iron group metal	284	Utilizing specified anode
251	Including arsenic, indium, or	285	Colored chromium coating
231	thallium	286	_
252	Tin, lead, or germanium is	200	Utilizing inorganic fluorine-
252	predominant constituent	207	containing bath
253	Utilizing organic compound-	287	Utilizing trivalent chromium-
∠ ງ ງ		0.00	containing bath
254	containing bath	288	Thiocyanate-containing
254	Organic sulfoxy-containing	289	Organic carboxyl compound-
255	Group VIII metal is predominant		containing
	constituent (i.e., Fe, Co, Ni, Pt, Pd, Rh, Ru, Ir, or Os)	290	Utilizing organic compound- containing bath
256	Utilizing specified anode	291	Copper
257	Platinum group metal-	292	Utilizing specified anode
	containing alloy (i.e.,	293	Utilizing inorganic cyanide-
	contains Pt, Pd, Rh, Ru, Ir,		containing bath
	or Os)	294	Selenium or tellurium-
258	Phosphorus-containing alloy	-	containing
259	Utilizing organic compound-	295	Utilizing alkaline bath
	containing bath	- -	

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296	Utilizing organic compound-	328	Utilizing sulfuric acid-
	containing bath		containing bath
297	Nitrogen-heterocyclic	329	Organic compound-containing
	compound-containing	330	Organic carboxyl compound-
298	And organic sulfur compound-		containing
	containing	331	Organic sulfoxy compound-
299	Lead		containing
300	Tin	332	Utilizing organic compound-
301	Utilizing alkaline bath	332	containing bath
302	Utilizing organic compound-	333	Oxide-containing coating (e.g.,
302	containing bath	333	lead dioxide, etc.)
303	Organic carbonyl compound-	334	ELECTROLYTIC SYNTHESIS (PROCESS,
303		334	COMPOSITION, AND METHOD OF
204	containing		PREPARING COMPOSITION)
304	Aldehyde-containing	225	•
305	Zinc	335	.Involving measuring, analyzing,
306	Utilizing inorganic cyanide-	226	or testing during synthesis
	containing bath	336	Utilizing fused bath (e.g.,
307	Nitrogen-heterocyclic		eliminating anode effect in a
	compound-containing		fused bath, etc.)
308	Organic carbonyl compound-	337	Current, current density, or
	containing		voltage
309	Utilizing alkaline bath	338	.Utilizing subatmospheric or
310	Nitrogen-heterocyclic		superatmospheric pressure
	compound-containing		during synthesis
311	Utilizing organic compound-	339	.Utilizing magnet or magnetic
	containing bath		field during synthesis
312	Nitrogen-heterocyclic	340	.Utilizing electromagnetic wave
	compound-containing		energy during synthesis (e.g.,
313	Organic sulfur compound-		visible light, etc.)
313	containing	341	.Utilizing AC or specified wave
314	Organic carbonyl compound-		form other than pure DC
214	containing	342	Reversing nonpulsed current or
315	Antimony		voltage
316	_	343	.Involving fuel cell
	.Forming nonmetal coating	344	.Utilizing bipolar membrane
317	Coating is predominantly	345	.Utilizing plural distinct
0.4.0	organic material	343	electrolytic cells where the
318	Phosphorus-containing coating		cells are separate containers
	(e.g., phosphate, etc.)	346	
319	Chromium-containing coating	340	Including decomposing or
	(e.g., chromate, etc.)	347	purifying cell
320	Predominantly iron or steel		Identical plural distinct cells
	substrate	348	.Utilizing fluidized bed or
321	Predominantly magnesium		particulate electrode
	substrate	349	.Recycling electrolytic product
322	Predominantly titanium,		produced during synthesis back
	vanadium, zirconium, niobium,		to production cell
	hafnium, or tantalum substrate	350	.Treating electrode, diaphram, or
323	Predominantly aluminum		membrane during synthesis
	substrate		(e.g., corrosion prevention,
324	Anodizing		etc.)
325	Specified alloy substrate		
326	Utilizing alkaline bath		
327	Utilizing chromium-containing		
J 2 /	bath		
	Dati		

351	.Treating electrolyte or bath	377	Utilizing membrane or
	without removal from cell		diaphragm between electrodes
	other than agitating, moving, regenerating, replenishing, or	378	Utilizing spacer between electrodes
	replacing consumed material	379	Utilizing nonmetal cell
	during synthesis		lining other than inorganic
352	.Utilizing emulsion, dispersion,		carbon or graphite
	or suspension electrolyte	380	Utilizing specified electrode
2.5.2	system		other than consumable
353	.Utilizing electrolyte system		electrode (e.g., cylindrical,
	having two or more separate immiscible layers	381	tapered, etc.)
354	.Utilizing fused bath	201	Inclined electrode (not horizontal or vertical)
355	Organic compound produced	382	Liquid electrode
356	Halogen containing	383	Bipolar electrode
357	Inorganic compound produced	384	Coated electrode
358	Silicon, boron, or phosphorus	385	Specified electrode
	containing		composition other than
359	Halogen containing		consumable inorganic carbon or
360	Nitrogen containing		graphite
361	Sulfur containing	386	Nonconsumable electrode
362	Oxygen containing		having inorganic carbon or
363	Alloy produced		graphite and a nonmetal
364	Silicon or aluminum containing		<pre>containing material (e.g., cermet, etc.)</pre>
365	Iron, cobalt, or nickel	387	Nonmetal containing (e.g.,
366	<pre>containingLead, zinc, titanium,</pre>	307	metal oxide, carbide, etc.)
300	zirconium, or hafnium	388	Utilizing coated or treating
	containing		electrode connecting or
367	Single metal produced		positioning means (e.g.,
368	Rare earth metal (At. No. 21,		coating, cooling, etc.)
	39 or 57-71)	389	Specific replenishing,
369	Lead, zinc, or cadmium		replacing, or feeding of
370	Iron, cobalt, nickel, or	200	consumable electrode material
	manganese	390	Involving specific process
371	Vanadium, niobium, tantalum,		startup other than mere turn on
	chromium, molybdenum, or	391	Collecting or controlling
	tungsten (V, Nb, Ta, Cr, Mo, or W)		fumes or gases produced during
372	Aluminum		synthesis
373	And elemental alkali or	392	Utilizing specific method or
	alkaline earth metal,		means to feed or replenish
	magnesium, beryllium, or		electrolyte or bath material
	nonmetal element other than	393	Purifying or treating
	halogen produced		electrolyte or bath prior to
374	Utilizing specified current	394	or after synthesis
	distributing means or method	394	Bath contains fluorine or bromine containing compound
	other than wire connecting		other than cryolite (Na3ALF6)
375	means	395	Fluorine or bromine
313	Utilizing specified distance between cathode and anode		containing compound contains
376	Agitating or moving		alkaline earth metal,
	electrolyte or bath during		beryllium, or magnesium (Ca,
	synthesis		Sr, Ba, Ra, Be, or Mg)

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396	Utilizing specified process	425	\ldots Diverse hetero atoms in the
	step to maintain bath		polycyclo ring system
	temperature	426	The hetero ring is six-
397	Titanium, zirconium, or		membered
	hafnium (Ti, Zr, or Hf)	427	Oxygen containing hetero ring
398	Titanium	428	The hetero ring is three-
399	Utilizing specified		membered
	electrode structure or anode	429	Cyclopentanohydrophenanthrene
	alloy composition		ring system containing
400	Utilizing diaphragm or		compound produced (e.g.,
	barrier between anode and		steroids, etc.)
	cathode	430	By fluorination of organic
401	Bath contains metal oxide or		compound other than
	fluorine containing compound		hydrocarbon or halogenated
402	Alkaline earth metal,		hydrocarbon
	beryllium, or magnesium	431	Nitrogen containing compound
403	Beryllium		produced
404	Magnesium	432	Nitrogen bonded to nitrogen
405	Bath contains alkali metal	433	Carbon triple bonded to
403	or fluorine containing	100	nitrogen
	compound	434	Carboxamide
406	Alkali metal (Li, Na, K, Rb,	435	C00- group containing
400	Cs, or Fr)	436	Oxygen containing
407	Lithium, sodium, or potassium	437	Hydroxy containing
407	Sodium	437	
409	Bath contains halide other	430	Carbocyclic ring containing
409	than sodium chloride	439	Carbonate or peroxy compound produced
410	Silicon, boron, or phosphorus	440	Carboxylic acid or derivative
	produced		produced
411	Halogen produced	441	Carboxylic acid ester produced
412	.Heating or cooling electrolyte	442	Carbocyclic ring containing
	or bath in production cell	443	Carbonyl or hydroxy group
	during synthesis except in		containing other than as part
	fused bath		of the carboxylic acid or
413	.Preparing organic compound		derivative
414	By polymerization	444	Sulfur containing compound
415	By dimerization		produced
416	Nitrogen containing dimer	445	Oxygen containing
	produced	446	Ketone produced
417	Adiponitrile	447	By electrolytic oxidation only
418	Carbonyl or hydroxy	448	Aldehyde produced
	containing dimer produced	449	By electrolytic oxidation only
419	From ring containing reactant	450	Alcohol or alcoholate produced
420	Silicon, boron, or phosphours	451	Halogen containing
	containing compound produced	452	By electrolytic oxidation only
421	Carbohydrate or derivative	453	Carbocyclic ring containing
	containing compound produced	454	Four or more hydroxy groups
	(e.g., streptomycin, etc.)	455	Oxygen containing compound
422	Heterocyclic compound produced		produced
423	Nitrogen containing hetero	456	Carbocyclic ring containing
	ring	457	Metal containing compound
424	Polycyclo ring system having		produced
	the hetero ring as one of the	458	Lead containing
	cyclos	459	Head containing compound
		100	produced
			<u></u>

460	Fluorine containing	501	Utilizing tubular or coated
461	Acyclic		electrode
462	Hydrocarbon produced	502	Chlorate
463	Carbocyclic ring containing	503	Alkali metal containing
464	.Preparing inorganic compound	504	Utilizing graphite or
465	Peroxy compound produced		inorganic carbon containing
466	Hydrogen peroxide		electrode
467	Utilizing mercury or amalgam	505	Utilizing coated electrode
407	electrode	506	Germanium, tin, or lead
468	Utilizing inorganic carbon	300	containing (Ge, Sn, or Pb)
400	containing electrode	507	Copper, silver, or gold
4.60	3	307	containing (Cu, Ag, or Au)
469	Boron containing	EOO	
470	Phosphorus containing	508	Hydroxide
471	Sulfur containing	509	Group VIII metal containing
472	Utilizing specified electrode	510	Alkali metal containing
473	Perhalogen acid or salt thereof	511	Utilizing bipolar electrode
	produced	512	Potassium hydroxide produced
474	Perchlorate or perchloric acid	513	Utilizing filter press cell
475	Permanganate produced		configuration
476	Potassium containing	514	Utilizing cell having three
477	Metal containing compound		or more compartments or units
	produced	515	Including gas compartment
478	Carbon containing	516	And elemental halogen
479	Cyanide		produced
480	Carbonate or bicarbonate	517	Utilizing structurally
		317	defined diaphragm or membrane
481	Lead containing		or diaphragm or membrane other
482	Alkali metal containing		than nonstructurally defined
483	Chromium containing		single layer cation exchange
484	Chromate		
485	Alkali metal containing		membrane having single-type
486	Chromic acid		cation exchange groups (e.g.,
487	Utilizing specified	E10	anion exchange membrane, etc.)
	electrode	518	Asbestos containing
488	Phosphorus containing	519	And polymer containing
489	Phosphate	520	Membrane having two or
490	Alkali or alkaline earth		more different ion exchange
230	metal, beryllium, or magnesium		groups in a single layer
	containing	521	Multilayered membrane
491	Nitrogen containing	522	Roughened membrane
492	Nitrite	523	Diaphragm or membrane
492			having a specified porosity
	Nitrate	524	Diaphragm or membrane
494	Sulfur containing (e.g.,		having nonelectrode layer
	sulfide, etc.)		bonded thereto or embedded
495	Sulfite, bisulfite, or		therein
	dithionite	525	Electrode bonded diaphragm
496	Sulfate or bisulfate		or membrane
497	Group VIII metal, lead, or	526	Utilizing specified
	copper containing (Fe, Co, Ni,	323	electrode (e.g., rod,
	Ru, Rh, Pd, Os, Ir, Pt, Pb, or		cylinder, etc.)
	Cu)	527	Mercury or amalgam cathode
498	Halogen containing	528	Specified anode
499	Oxygen containing	240	-
500	Hypochlorite or chlorite	F20	composition
-		529	Purifying the cathode

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530	Concentrically arranged electrodes	555	Carbon containing compound produced
531	Foraminous or perforated	556	Halogen containing compound
	(e.g., mesh, screen, etc.)		produced
532	Laminated or coated	557	.Preparing alloy
533	Polymer or graphite or	558	Amalgam produced (e.g.,
	inorganic carbon containing		utilizing mercury or amalgam
	coating		electrode during synthesis,
534	Raney metal containing	E E O	etc.)
	coating (e.g., Ni-Al alloy,	559	Precious metal containing (Ru,
F 2 F	etc.)	F.C.0	Rh, Pd, Os, Ir, Pt, Ag, or Au)
535	Valve metal containing	560	.Preparing single metal
	electrode substrate (i.e., Ta,	561	Utilizing bipolar electrode
	Nb, Hf, Zr, Ti, V, W, Be, or	562	Mercury produced
536	Al)	563	Arsenic, antimony, or bismuth
550	<pre>Treating electrolyte or bath material prior to</pre>	F.C.4	produced (As, Sb, or Bi)
	synthesis other than heating,	564	Gallium, germanium, indium,
	cooling, or replacing consumed		vanadium, or molybdenum
	material during synthesis	565	produced
537	Controlling electrolyte	566	Precious metal producedUtilizing specified electrode
	flow other than by flow	300	other than consumable precious
	through a diaphragm or		metal containing electrode
	membrane	567	Alloy electrode
538	Oxide	568	Leaching, dissolving, or
539	Manganese containing	300	extracting prior to synthesis
540	And elemental zinc or	569	Utilizing nitrogen containing
	elemental manganese produced	303	material
541	Utilizing specified	570	Utilizing halogen containing
	electrode	370	material
542	Titanium, zirconium,	571	Silver or gold
	hafnium, vanadium, niobium, or	572	Chromium produced
	tantalum containing (Ti, Zr,	573	Manganese produced
	Hf, V, Nb, or Ta)	574	Copper produced
543	Group VIII metal containing	575	Utilizing specified electrode
544	Germanium, tin, or lead		other than consumable copper
	containing		containing electrode
545	Copper, silver, gold, zinc,	576	Specified anode
	cadium, or mercury containing	577	Elemental carbon containing
T 4.6	(Cu, Ag, Au, Zn, Cd, or Hg)		(e.g., graphite, etc.)
546	Hydrate	578	Lead containing
547	Germanium, tin, or lead	579	Iron, cobalt, or nickel
F 4.0	containing		containing
548	Iron, cobalt, or nickel	580	Leaching, dissolving, or
Г 4 О	containing		extracting prior to synthesis
549	Silicon, boron, or phosphorus	581	Utilizing organic material
EEO	containing compound produced	582	Utilizing halogen containing
550 ==1	Phosphine		material
551	Nitrogen containing compound produced	583	Utilizing sulfur containing
EEO	-		material
552 553	AmmoniaNitric acid or oxide of	584	Recycling electrolyte or
223	nitrogen		bath material back to
554	Sulfur containing compound		production cell after
JJ4	produced		synthesis
	produced	585	Bath contains organic material

586	Purifying or treating electrolyte or bath prior to	619	Fluorine, bromine, or iodine produced
	or after synthesis	620	Chlorine and hydrogen produced
587 588	Ion, cobalt, or nickel producedSpecified anode other than	621	Utilizing specified metal or alloy cathode
300	consumable iron, cobalt, or	622	Utilizing specified electrode
	nickel containing	022	other than graphite or
589	Leaching, dissolving, or		inorganic carbon
	extracting prior to synthesis	623	Mercury or amalgam cathode
590	Utilizing organic material	624	Diaphragm or membrane bonded
591	Utilizing halogen containing		electrode
	material	625	Coated electrode
592	Of iron	626	Ozone produced
593	Of iron	627	Deuterium or tritium produced
594	Nickel	628	Oxygen and hydrogen produced
595	Bath contains organic	629	Utilizing inorganic solid
	material		electrolyte
596	Bath pH below 5	630	Utilizing specified electrode
597	Lead produced	631	Specified single metal or
598	Utilizing specified electrode		alloy
	other than consumable lead	632	Group VIII metal
	containing electrode	633	Oxygen produced
599	Leaching, dissolving, or	634	Utilizing inorganic solid
	extracting prior to synthesis		electrolyte
600	Utilizing halogen containing	635	Utilizing nonmetal containing
	material		electrode
601	Bath contains organic material	636	Utilizing group VIII metal
602	Zinc produced		alloy electrode
603	Utilizing specified electrode	637	Hydrogen produced
	other than consumable zinc	638	Utilizing specified electrode
	containing electrode	639	Specified single metal or
604	Leaching, dissolving, or		alloy
	extracting prior to synthesis	640	ELECTROLYTIC EROSION OF A
605	Utilizing organic material		WORKPIECE FOR SHAPE OR SURFACE
606	Utilizing halogen containing		CHANGE (E.G., ETCHING,
	material		POLISHING, ETC.) (PROCESS AND
607	Utilizing sulfur containing		ELECTROLYTE COMPOSITION)
	material	641	.With control responsive to
608	Removing iron or iron		sensed condition
	containing material	642	To adjust voltage across or
609	Bath contains silver,		size of tool-workpiece gap
	strontium, or organic material	643	In response to sensed voltage
610	Tin produced	644	In response to sensed voltage
611	Leaching, dissolving, or		or current
	extracting prior to synthesis	645	.With measuring, testing, or
612	Utilizing halogen containing		sensing
	material	646	.With programmed, cyclic, or time
613	Utilizing sulfur containing		responsive control
	material	647	Including nonelectrolytic
614	Bath contains silicon or		erosion
	organic material	648	Using diverse-type tool
615	.Preparing nonmetal element		electrodes
616	Utilizing bipolar electrode	649	Eroding workpiece to match
617	Sulfur or nitrogen produced		nonplanar surface shape of
618	Halogen produced		tool electrode

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650	Cleaning, recycling, or reusing electrolyte	680	More than 20 weight percent of one or more phosphoric acids
651	Moving tool or workpiece	681	Chromium containing
652	.Gap maintenance or defined tool-	682	Phosphorus containing
	workpiece gap	683	Cyano compound containing
653	Using tool electrode with two	000	(e.g., hydrogen cyanide, etc.)
	or more holes for passage of	684	Organic material containing
	electrolyte	685	Nitrate containing (e.g.,
654	Moving tool electrode	003	nitric acid, sodium nitrate,
655	.With irradiation or illumination		etc.)
656	.Eroding workpiece of nonuniform	686	.Moving tool electrode
030	internal electrical	687	ELECTROLYTIC MATERIAL TREATMENT
	characteristics	007	(PRODUCT, PROCESS, AND
657	.Internal battery action		ELECTROLYTE COMPOSITION)
658	.Simple alternating current	688	Organic
659	Plural separate currents or	689	Fibrous
033		690	Bleaching
660	voltages applied	691	-
000	.Preliminary cleaning or shaping	692	Dyeing Hides or skins
661	of workpiece		
001	Nonelectrolytic (e.g.,	693	Cleaning or refining
	<pre>mechanical grinding, milling, machining, etc.)</pre>	694	Protection
662	.With mechanical abrasion or	695	Oil or fat
002	grinding	696	Hydrocarbon oil
663		697	Sugar
664	Rotating tool or workpiece	698	Cellulosic
	.Sharpening or point making	699	Rubber or latex
665	.Aperture making	700	Bleaching
666	.Using mask	701	Biological (e.g., sterilizing,
667	Of photoresist or radiation		etc.)
C C O	resist	702	Removing metal
668	Local application of electrolyte	703	Using membrane
669	Using surface tension or	704	.Metal or metal alloy
	capillary action to hold	705	Removing foreign material
	electrolyte in contact with workpiece		(e.g., cleaning, etc.)
670	Through open nozzle or flow-	706	Internal battery action
070	through piping (e.g.,	707	From precious metal or
	unsupported jet, etc.)		precious metal alloy
671	.Agitation or vibration of	708	Using anode containing
071	electrolyte		aluminum
672	.Defined electrolyte movement or	709	With solid-workpiece moving
072	pressure		contact (e.g., brushing, etc.)
673	Regenerating or rehabilitating,	710	With changing current
075	per se, of electrolyte	711	Simple alternating current
674	Electrolyte composition or	712	Nonelemental material from
074	defined electrolyte		ferrous metal
675	Less than 50 weight percent	713	Using fused bath (e.g.,
075	water		molten salt, etc.)
676	More than 20 weight percent	714	Using acidic electrolyte
070	organic material	715	Containing one or more
677	With one or more phosphoric		phosphoric acids
577	acids	716	Containing nitric acid
678	With sulfuric acid	717	Entire identifiable elemental
679	More than 20 weight percent		layer or portion removed
0,5	chromium compound		(e.g., stripping, etc.)
	CIII OMITAM COMPONIA		

718 719	Precious metal removedTin removed	752	And treatment with oxygen or ozone
_	Nickel removed	753	
720			Using particle bed
721	Copper removed	754	As electrode
722	<pre>Using electrolyte containing surface active agent (e.g.,</pre>	755	With mixing, agitating, or gas- liquid contacting
	<pre>foaming or wetting agent, etc.)</pre>	756	<pre>Using oxygenating gas (e.g., ozone, air, etc.)</pre>
723	•	757	
723 724	Using acidic electrolyte	757	Bubbling (e.g., for flotation
	Object protection	550	of solids, etc.)
725	With control responsive to sensed condition	758	<pre>Using porous electrode (e.g., perforated, etc.)</pre>
726	Current sensed	759	Using coated electrode (e.g.,
727	Voltage sensed		having electrocatalytic
728	And programmed, cyclic, or		coating, etc.)
	time responsive control	760	Using electrode containing
729	With programmed, cyclic, or		precious metal or free carbon
	time responsive control		(e.g, insoluble electrode,
730	Internal battery action (e.g.,	7.61	etc.)
	using sacrificial anode, etc.)	761	Using electrode containing
731	Ferrous metal	T.60	ferrous metal
732	Using anode containing	762	.Alkali-forming metal hydroxide
	aluminum	763	.Gas, vapor, or critical fluid
733	Using anode containing	764	Internal battery action
	magnesium	765	Using solid electrolyte
734	Metal imbedded in asphalt,	766	.Solid (e.g., articles,
	concrete, stone, or masonry,		particles, ore, etc.)
	(e.g., reinforced concrete,	767	Containing precious metal
	etc.)		(e.g., beneficiating ore,
735	Ferrous metal		etc.)
736	Stainless steel	768	Containing free carbon (e.g.,
737	Using anode containing free		graphite, carbon black, etc.)
	carbon (e.g., graphite, carbon	769	Glass, silica, quartz, or
	fibers, etc.)		optical material (e.g.,
738	Using anode containing		contact lenses, etc.)
	precious metal	770	.Using membrane
739	Using anode containing free	771	.Removing metal
	carbon (e.g., graphite, carbon	772	Copper
	fibers, etc.)	775	ELECTROLYTIC ANALYSIS OR TESTING
740	Vessel (e.g., ship hull, steam		(PROCESS AND ELECTROLYTE
	boiler, etc.)		COMPOSITION)
741	Containing iron	775.5	.For corrosion
742	.Water, sewage, or other waste	776	Testing by internal battery
7.40	water	776 5	action
743	With control responsive to sensed condition	776.5	Of coating, coated substrate, or imbedded object
744	With programmed, cyclic, or	777	Of ferrous metal
	time responsive control	777.5	.Involving enzyme or micro-
745	Internal battery action		organism
746	Using membrane	778	And using semipermeable
747	With filtering		membrane
748	Plural membranes	778.5	.For halogen or halogen
749	With recycle or reuse		containing compound
750	Removing metal	779	In biological fluid (e.g.,
751	With filtering		urine, etc.)

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770 -		700	
779.5	Gaseous halogen or halogen containing compound	799	MISCELLANEOUS ELECTROLYSIS
780	Using electrode containing precious metal or free carbon		
780.5	.For nitrogen or nitrogen containing compound	CROSS-F	REFERENCE ART COLLECTIONS
781	Including nitrogen oxide (e.g., gaseous nitrogen dioxide,	915	ELECTROLYTIC DEPOSITION OF SEMICONDUCTOR
	dissolved sodium nitrate,	916	SEQUENTIAL ELECTROLYTIC AND
	etc.)		NONELECTROLYTIC, OR
781.5	.For alkali metal, alkaline earth		NONELECTROLYTIC AND
	metal, or compound thereof		ELECTROLYTIC COATING FROM THE
782	.For oxygen or oxygen containing		SAME BATH
700 5	compound (except water)	917	TREATMENT OF WORKPIECE BETWEEN
782.5	Using semipermeable membrane		COATING STEPS
783	Gaseous oxygen or oxygen	918	USE OF WAVE ENERGY OR ELECTRICAL
783.5	containing compound		DISCHARGE DURING PRETREATMENT
784	Using solid electrolyte		OF SUBSTRATE OR POST-TREATMENT
704	Gaseous oxygen or oxygen containing compound	919	OF COATING
784.5	In combustible gas (e.g.,	920	WATERPROOFING ELECTROLYTIC COATING OF CIRCUIT
704.5	air/fuel mixture for internal	920	BOARD OR PRINTED CIRCUIT
	combustion engine, etc.)		(OTHER THAN SELECTED AREA
785	With heating or temperature		COATING)
	sensing	921	ELECTROLYTIC COATING OF PRINTING
785.5	Gaseous oxygen or oxygen		MEMBER (OTHER THAN SELECTED
	containing compound		AREA COATING)
786	Using electrode containing	922	ELECTROLYTIC COATING OF MAGNETIC
	precious metal or free carbon		STORAGE MEDIUM (OTHER THAN
786.5	.For sulfur or sulfur containing		SELECTED AREA COATING)
	compound	923	SOLAR COLLECTOR OR ABSORBER
787	.For organic compound	924	ELECTROLYTIC COATING SUBSTRATE
787.5	.For pH		PREDOMINANTLY COMPRISED OF
788	.For water (e.g., moisture, etc.)	925	SPECIFIED SYNTHETIC RESIN .Synthetic resin is electrically
788.5	.Including titration	923	conductive
789	.For ion concentration (e.g., ion	926	.Polyamide or polyimide (e.g.,
789.5	activity, pKa, etc.)Cations	<i>J</i> <u>Z</u> 0	nylon, etc.)
790	.For composition of metal or	927	.Polyolefin (e.g., polyethylene,
750	metal alloy		polypropylene, etc.)
790.5	.For properties of solid material	928	.ABS Copolymer
	(e.g., surface area, etc.)		
791	Of coating or coated substrate		
	(e.g., thickness, bonding		
	strength, etc.)	FOREIGN	N ART COLLECTIONS
791.5	Defects		
792	.Of biological material (e.g.,	FOR 000	CLASS-RELATED FOREIGN DOCUMENTS
	urine, etc.)		
792.5	.Using ion exchange resin		
793	.Using semipermeable membrane		
793.5	.Tracking chemical reactions		
794	Coating (e.g., electroless,		
704 5	etc.)		
794.5	.Using electrode containing		
	precious metal or free carbon		